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Amendments to the Claims

- 1. (Currently Amended) A method of forming a semiconductor structure comprising a substrate having a patterned Oxide-Nitride-Oxide (ONO) insulating layer over a portion thereof, comprising and characterized by the steps of forming an insulating layer comprising an Oxide-Nitride-Silicon layered structure on the substrate, applying a photoresist to a silicon surface of the Oxide-Nitride-Silicon layered structure as part of a patterning process and stripping the photoresist from the silicon surface of the Oxide-Nitride-Silicon layered structure once a required patterning step has been completed, and subsequently re-oxidizing the silicon layer of the remaining Oxide-Nitride-Silicon structure so as to form an ONO insulating layer structure.
- 2. (Original) A method as claimed in claim 1, wherein the silicon layer comprises an amorphous silicon layer.
- 3. (Previously Presented) A method as claimed in claim 1, wherein a non-volatile memory cell is applied as part of the semiconductor structure, which non-volatile memory cell employs the ONO insulating layer between a floating gate and control gate thereof.
- 4. (Original) A method as claimed in claim 3, wherein the non-volatile memory cell is applied with a control gate formed from a conductive layer which also servers to form part of a peripheral semiconductor structure.

Scrial No.: 09/989,250

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